

*Sub B2 and*  
 a light emitting layer that defines a film formation region, the film formation region of said light emitting layer being equal to, or greater than, the film formation region of said hole injection/transportation layer.

2. (Amended) A method of manufacturing an organic EL device having a laminated film of at least two layers is formed by providing a composition for forming said layers from an ink jet head, comprising the step of:

*A1*  
*cond*  
 providing a hole injection/transportation layer and a light emitting layer, such that a relationship of  $A \leq B$  is satisfied, A being a discharge amount of a composition that forms said hole injection/transportation layer, and B being a discharge amount of a composition that forms said light emitting layer.

3. (Amended) An organic EL device manufactured according to the method of claim 2.

4. (Amended) A method of manufacturing an organic EL device having a structure in which a laminated film of at least two layers is formed by providing a composition for forming said layers from an ink jet head, comprising the step of:

providing a hole injection/transportation layer and a light emitting layer, such that a relationship of  $A \leq B$  is satisfied, A being a sum of discharge amounts of a composition that forms said hole injection/transportation layer, and B being a sum of discharge amounts of a composition that forms said light emitting layer.

5. (Amended) An organic EL device manufactured according to the method of claim 4.

Please add new claims 6-9 as follows:

*A2*  
*Sub B2*  
 --6. The organic EL device according to claim 1, the device comprising the hole injection/transportation layer and the light emitting layer between a cathode and an anode and light traveling from the device through the cathode side.--